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Substitute for form 1449A/B/PTO			- Application Number	10/810,718-Conf. #8917
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as recossary)			Filing Date	March 29, 2004
			First Named Inventor	Panayotia C. Andricacos
			Art Unit	1753
			Examiner Name	Not Yet Assigned
heet 1	of	1	Attorney Docket Number	20140-0255-US3

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Examina:	Cite No.	Document Number Number-Kind Code ² (# known)	Publication Date	Name of Patentee or	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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K				LANDAU, et al.	

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		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journel, sental, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city	r ·
	CA	A Novel Electrolyte Composition for Copper Pleting in Wafer Metallization, Electrochemical Processing in ULSI Fabrication and Semiconductor/Metal Deposition II: Proceedings of the International Symposium; P.C.: Uziel LANDAU, et al., The Electrochemical Society, Inc.	
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